

CPC**COOPERATIVE PATENT CLASSIFICATION****C09G****POLISHING COMPOSITIONS OTHER THAN FRENCH POLISH;
SKI WAXES****C09G 1/00****Polishing compositions** (French polish [C09F 11/00](#); detergents [C11D](#))**C09G 1/02**

- containing abrasives or grinding agents {(abrasives as such [C09K 3/14](#); polishing of semi-conductors [H01L](#))}

C09G 1/04

- Aqueous dispersions ([C09G 1/02](#) takes precedence)

C09G 1/06

- Other polishing compositions

C09G 1/08

- based on wax

C09G 1/10

- based on mixtures of wax and natural or synthetic resin

C09G 1/12

- mixtures of wax and silicon-containing polycondensates

C09G 1/14

- based on non-waxy substances

C09G 1/16

- on natural or synthetic resins

C09G 1/18

- on other substances

C09G 3/00**Ski waxes**